

17
FEB 23 2004
PATENT & TRADEMARK OFFICE

DECLARATION FOR PATENT APPLICATION

(02S1239)

As a below named inventor, I declare that my residence, mailing address and citizenship are as stated below above my name; I believe that I am the original, first and sole inventor (if only one name is listed below) or an original, first and joint inventor (if plural names are listed below) of the subject matter which is claimed and for which a patent is sought on the invention entitled:

MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE

the specification of which (check applicable box(es))

☐ is attached hereto.

☒ was filed on September 30, 2003 as United States Application No. 10/673,262
or PCT International Application No.

☐ and was amended on

I hereby state that I have reviewed and understand the contents of the above-identified specification, including the claims, as amended by any amendment referred to above.

I acknowledge the duty to disclose information which is material to patentability as defined in 37 CFR 1.56.

I hereby claim foreign priority benefits under 35 U.S.C. 119(a)-(d) or 365(b) of any foreign application(s) for patent or inventor's certificate, or 35 U.S.C. 365(a) of any PCT International application which designated at least one country other than the United States, listed below and have also identified below any foreign application for patent or inventor's certificate, or PCT International application having a filing date before that of the application on which priority is claimed:

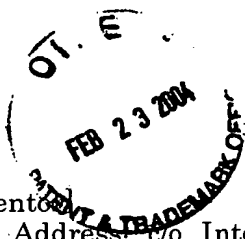
None

I hereby claim the benefit under 35 U.S.C. 119(e) of any United States provisional applications listed below.

I hereby claim the benefit under 35 U.S.C. 120 of any United States application(s) or 35 U.S.C. 365(c) of any PCT International application designating the United States, listed below and, insofar as the subject matter of each of the claims of this application is not disclosed in the prior United States application or PCT International application in the manner provided by the first paragraph of 35 U.S.C. 112, I acknowledge the duty to disclose information which is material to patentability as defined in 37 CFR 1.56, which became available between the filing date of the prior application and the national or PCT international filing date of this application.

I hereby appoint as my attorneys, with full power of substitution and revocation, to prosecute this application and transact all business in the Patent and Trademark Office connected therewith: the registrants of Oblon, Spivak, McClelland, Maier & Neustadt, P.C., Fourth Floor, 1755 Jefferson Davis Highway, Arlington, Virginia 22202, Customer No. 22850, or any one of them. Send correspondence to Oblon, Spivak, McClelland, Maier & Neustadt, P.C., Fourth Floor, 1755 Jefferson Davis Highway, Arlington, Virginia 22202.

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code and that such willful false statements may jeopardize the validity of the application or any patent issued thereon.



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(02S1239)

[1st Inventor]

Mailing Address: c/o Intellectual Property Division, Toshiba Corporation, 1-1, Shibaura 1-chome,
Minato-ku, Tokyo 105-8001, Japan

Residence Address: Yokohama-shi, Japan

Citizenship: Japan

Keitaro Imai

FEB. - 4. 2004

Date:

[2nd Inventor]

Mailing Address: c/o Intellectual Property Division, Toshiba Corporation, 1-1, Shibaura 1-chome,
Minato-ku, Tokyo 105-8001, Japan

Residence Address: Tokyo, Japan

Citizenship: Japan

Koji Yamakawa

FEB. - 4. 2004

Date:

[3rd Inventor]

Mailing Address: c/o Intellectual Property Division, Toshiba Corporation, 1-1, Shibaura 1-chome,
Minato-ku, Tokyo 105-8001, Japan

Residence Address: Yokohama-shi, Japan

Citizenship: Japan

Hiroshi Itokawa

FEB. - 4. 2004

Date:

[4th Inventor]

Mailing Address: c/o Intellectual Property Division, Toshiba Corporation, 1-1, Shibaura 1-chome,
Minato-ku, Tokyo 105-8001, Japan

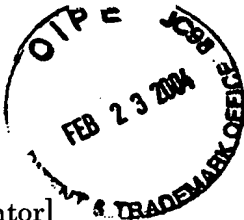
Residence Address: Yokohama-shi, Japan

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Katsuaki Natori

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Date:



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[5th Inventor]

Mailing Address: c/o Intellectual Property Division, Toshiba Corporation, 1-1, Shibaura 1-chome,
Minato-ku, Tokyo 105-8001, Japan

Residence Address: Yokohama-shi, Japan

Citizenship: Japan

Osamu Arisumi

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FEB. - 4. 2004

Date:

[6th Inventor]

Mailing Address: c/o Intellectual Property Division, Toshiba Corporation, 1-1, Shibaura 1-chome,
Minato-ku, Tokyo 105-8001, Japan

Residence Address: Tokyo, Japan

Citizenship: Japan

Keisuke Nakazawa

Keisuke Nakazawa

FEB. - 4. 2004

Date:

[7th Inventor]

Mailing Address: Shurosusenzoku B, 6-30-9, Hatanodai, Shinagawa-ku, Tokyo, Japan

Residence Address: Tokyo, Japan

Citizenship: Korea

Bum-ki Moon

Date:



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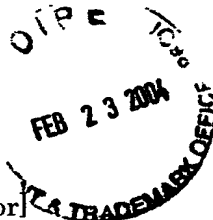
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Keitaro Imai

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Minato-ku, Tokyo 105-8001, Japan

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Citizenship: Japan

Koji Yamakawa

Date:

[3rd Inventor]

Mailing Address: c/o Intellectual Property Division, Toshiba Corporation, 1-1, Shibaura 1-chome,
Minato-ku, Tokyo 105-8001, Japan

Residence Address: Yokohama-shi, Japan

Citizenship: Japan

Hiroshi Itokawa

Date:

[4th Inventor]

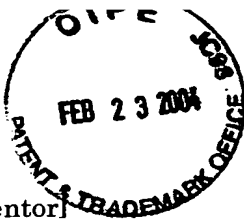
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Katsuaki Natori

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Minato-ku, Tokyo 105-8001, Japan

Residence Address: Yokohama-shi, Japan

Citizenship: Japan

Osamu Arisumi

Date:

[6th Inventor]

Mailing Address: c/o Intellectual Property Division, Toshiba Corporation, 1-1, Shibaura 1-chome,
Minato-ku, Tokyo 105-8001, Japan

Residence Address: Tokyo, Japan

Citizenship: Japan

Keisuke Nakazawa


Date:

[7th Inventor]

Mailing Address: c/o Infineon Technologies North America Corp., 1983 Route. 52, Suite 1,
Hopewell Junction, New York 12533, U.S.A.

Residence Address: New York

Citizenship: Korea



Bum-ki Moon

Date:

Jan. 22nd, 2004